

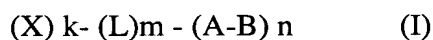
AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the application:

LISTING OF CLAIMS:

Claims 1-5. (canceled).

6. (original): A silver halide photographic lightsensitive material comprising a support having thereon at least one lightsensitive silver halide emulsion layer containing an emulsified dispersion, wherein the lightsensitive material contains at least one compound represented by general formula (I), and at least one surfactant having a critical micelle concentration of 4.0×10^{-3} mol/L or less in an amount of 0.01% by weight or more based on all the ingredients contained in the lightsensitive layer:



wherein X represents an adsorbing group to silver halide or a light-absorbing group having at least one atom selected from the group consisting of N, S, P, Se and Te; L represents a bivalent linking group having at least one atom selected from the group consisting of C, N, S and O; A represents an electron-donating group; B represents a leaving group or a hydrogen atom, wherein after $-(A-B)_n$ portion is oxidized, B is eliminated or deprotonated thereby to form a radical A^\bullet ; k and m independently represent an integer of 0 to 3; and n represents 1 or 2.

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7. (currently amended): The silver halide photographic lightsensitive material according to claim 26, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (a) to (d):

- (a) parallel main planes thereof are (111) faces,
- (b) an aspect ratio thereof is 2 or more,
- (c) ten or more dislocation lines per grain are present, and
- (d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%.

8. (currently amended): The silver halide photographic lightsensitive material according to claim 26, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (a), (d) and (e):

- (a) parallel main planes thereof are (111) faces,
- (d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%, and
- (e) hexagonal tabular grains each having at least one epitaxial junction per grain at an apex portion and/or a side face portion and/or a main plane portion thereof.

9. (currently amended): The silver halide photographic lightsensitive material according to claim ~~2~~6, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (d), (f) and (g):

(d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%,

(f) parallel main planes thereof are (100) faces, and

(g) an aspect ratio thereof is 2 or more.

10. (currently amended): The silver halide photographic lightsensitive material according to claim ~~2~~6, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (g), (h) and (i):

(g) an aspect ratio thereof is 2 or more,

(h) parallel main planes thereof are (111) faces or (100) faces, and

(i) tabular grains each having a silver chloride content of at least 80 mol%.

11. (currently amended): The silver halide lightsensitive material according to claim ~~4~~6, wherein the emulsified dispersion further contains a high-boiling organic solvent having a dielectric constant of 7.0 or less.

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12. (currently amended): The silver halide photographic lightsensitive material according to claim 311, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (a) to (d):

- (a) parallel main planes thereof are (111) faces,
- (b) an aspect ratio thereof is 2 or more,
- (c) ten or more dislocation lines per grain are present, and
- (d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%.

13. (currently amended): The silver halide photographic lightsensitive material according to claim 311, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (a), (d) and (e):

- (a) parallel main planes thereof are (111) faces,
- (d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%, and
- (e) hexagonal tabular grains each having at least one epitaxial junction per grain at an apex portion and/or a side face portion and/or a main plane portion thereof.

14. (currently amended): The silver halide photographic lightsensitive material according to claim 311, wherein 50% or more of the total projected area of all the silver

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halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the following requirements (d), (f) and (g):

(d) tabular silver halide grains each formed of silver iodobromide or silver chloriodobromide whose silver chloride content is less than 10 mol%,

(f) parallel main planes thereof are (100) faces, and

(g) an aspect ratio thereof is 2 or more.

15. (currently amended): The silver halide photographic lightsensitive material according to claim 311, wherein 50% or more of the total projected area of all the silver halide grains contained in the lightsensitive layer is occupied by silver halide grains satisfying the

following requirements (g), (h) and (i):

(g) an aspect ratio thereof is 2 or more,

(h) parallel main planes thereof are (111) faces or (100) faces, and

(i) tabular grains each having a silver chloride content of at least 80 mol%.

Claims 16-20. (canceled).